

Growth of mixed materials in the Be/W/O system in fusion devices

Mateus, R. *, Carvalho, P.A. *, Franco, N. *, Alves, E. *, Porosnicu, C. ** and Lungu, C.P.**

* Associação Euratom/IST, Instituto de Plasmas e Fusão Nuclear, Instituto Superior Técnico, Universidade de Lisboa, 1049-001 Lisboa, Portugal

** Association EURATOM-MEdC, National Institute of Lasers, Plasma and Radiation Physics, 077125 Bucharest, Romania

Email: rmateus@ipfn.ist.utl.pt

Beryllium (Be) and tungsten (W) will be used as plasma facing materials in the next future in fusion reactors with the purpose to take advantage from the individual properties of each metal. Nevertheless, different events will take place during reactor operation such as erosion of the exposed surfaces, transport of impurities in the main plasma and re-deposition of the eroded material in other locations. Moreover, the heat load in the reactor walls and the kinetic energy of the impinging particles will induce the formation of Be-W intermetallics and oxides, where oxygen (O) acts as a contaminant. As a consequence, the chemical, physical and the mechanical properties of the exposed surfaces may evolve over time, and the formation of new phases should be investigated [1,2] in order to predict the lifetime of the parts under plasma exposure.

In this work, Be and W films with thicknesses of 100 and 200 nm were deposited on W and Be plates, respectively, by using the thermionic vacuum arc (TVA) method [1]. Afterwards, the samples were annealed in vacuum at different temperatures and analysed with ion and electron beam techniques for elemental quantification, and by grazing X-ray diffraction (XRD) for phase identification [2]. The use of ion beam techniques is particular important in the study of Be samples, while Be is not detected by EDS. Electron microscopy images were collected with secondary (SE) and backscattering electrons (BSE) for topographic and chemical analysis, respectively. Energy-dispersive X-ray spectrometry (EDS) was also carried out for elemental quantification and mapping.

All the experiments performed in the four batches lead us to the same conclusions. The Be-W reactivity is very weak up to 700°C and it becomes very fast at 800°C, leading to a strong Be-W interdiffusion and compound formation, being the growth of Be₂W and Be₁₂W identified by XRD. The Be-W reactivity is accomplished with the formation of a BeO superficial layer, as it is concluded from EDS mapping, due to the affinity of Be to react with O. In the case of W films deposited on Be plates, ion beam analysis evidence that, typically, Be diffuses through the superficial W layers and oxidizes at the surface.

A smooth delamination behaviour induced by thermal stress was observed in the Be films after annealing at higher temperatures. The Be-W interdiffusion and the growth of the intermetallic components may be followed by the chemical analysis of the delaminated zones. Fig. 1a shows one of these events occurred at 700°C in the 200 nm Be batch, where the formation of a new phase is starting along the edge of the delaminated area. From the comparison of both SE and BSE images in Fig. 1b and 1c, we conclude that the new phase has a high W content. After annealing at 800°C, all the delaminated areas become covered with the new component (Fig. 1d), which starts to grow up along the entire annealed surface (Fig. 1e and 1f). Additionally, EDS data reveal that the formation of BeO is homogeneously distributed in the surface and it is enhanced at higher temperatures (Fig. 2), while the corresponding diffractograms evidence that BeO seems to be restricted to a very thin and superficial layer, and that Be₁₂W is the main intermetallic composition up to 800°C.

This work has been carried out in the frame of the contracts of association between EURATOM, IST (Portugal) and MEdC (Romania).

[1] Porosnicu C. *et al.*, *Journal of Nuclear Materials*, **415**, S713-S716, 2011.
 [2] Mateus R. *et al.*, *Journal of Nuclear Materials*, **442**, S320–S324, 2013.

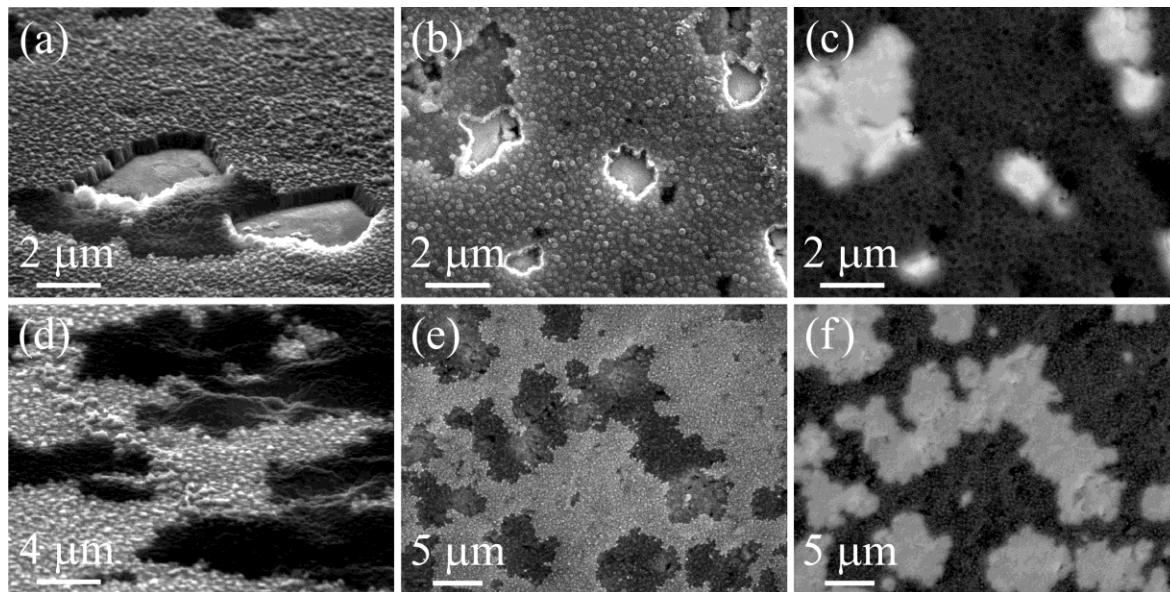


Figure 1. SE tilted view of a delaminated zone (a) and corresponding SE (b) and BSE (c) top views obtained from the 200nm Be film deposited on W after annealing at 700°C/4h; similar images obtained from the same batch after annealing at 800°C/4h in (d), (e) and (f).

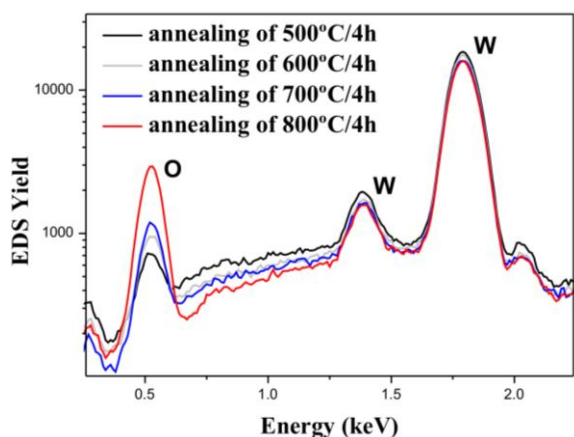


Figure 2. EDS spectra collected from the 200nm Be batch after annealing (colours online).

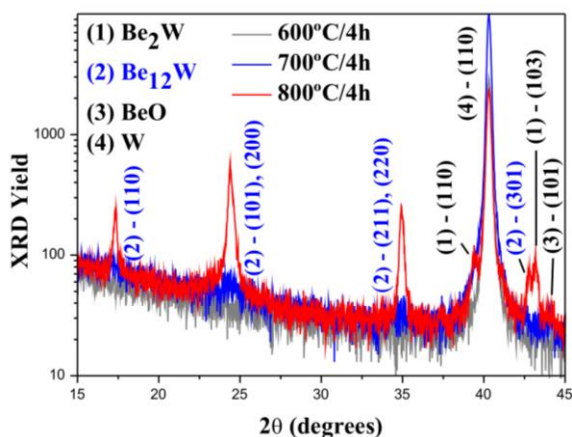


Figure 3. XRD spectra collected from the 200 nm Be batch after annealing (colours online).